IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

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Assignee:

Siliconix, Incorporated

itle:

TRENCH DMOS POWER TRANSISTOR WITH FIELD-SHAPING BODY PROFILE AND THREE-DIMENSIONAL GEOMETRY

Serial No.:

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Examiner:

J. Carroll

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AMENDMENT

MANUE 2500

Sir:

In response to the Office Action of 6/8/94, Applicant submits the following remarks and requests the Examiner's reconsideration of Claims 17-29.

REMARKS

Claims 17-29 are pending.

The Examiner rejected Claims 17-29 under 35 U.S.C. § 103 over Tonnel (U.S. Patent 4,420,379), stating:

[With respect to Claim 17, a] peripheral cell shown in Figure 3 includes at least one trench extending into epitaxial layer (21) to a finite depth, d1, source regions (26) formed in a body region portion (25) that extends a finite depth, d2, at one location, whereby the body region includes a peripheral portion (22) at another location extending a finite depth, d3. Examining cross-section profile shown in Figure 12, we find that, as opposed to the rendering of Figure 3, Tonnel fully expected that the each of d1 and d2 to be less than d3, that d1 exceeds d2 and that a distance between either trench and either peripheral body region (22) exceed a distance between either trench and an adjacent body portion region (25). We thus conclude it to have been obvious for one to have accordingly disposed the regions, portions and trenches of the Figure 3 embodiment.

In re Claims 22 and 23, evidently from Figures 3 and 12, Tonnel expected a DMOS

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